

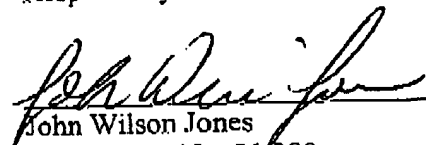
In the Specification:

Please amend the first full paragraph on page 7 of the originally filed specification as follows:

Such phosphonate materials are used in conjunction with hydrofluoric acid or hydrochloric acid or such conventional acid systems as hydrochloric/hydrofluoric acid systems and organic/hydrofluoric acid systems which include formic/hydrofluoric acid mixtures and include ~~Commercially available acid systems which are particularly preferred are~~ "CLAY ACID", "RMS ACID" and "RHF ACID". ~~"CLAY ACID" is a fluoroboric acid solution~~ solutions ~~available from Dowell Schlumberger. "RMS ACID" is available from BJ Services and consists primarily of a hydrochloric acid and hexafluorophosphoric acid mixture~~ mixture mixtures as well as ~~The "RHF ACID" is a retarded hydrofluoric acid system~~ systems consisting of 12% hydrochloric acid and 3% hydrofluoric acid using ammonium bifluoride as the source of hydrofluoric acid and an aluminum salt as a retarder. ~~"RHF ACID" is available from Halliburton Company.~~

Respectfully submitted,

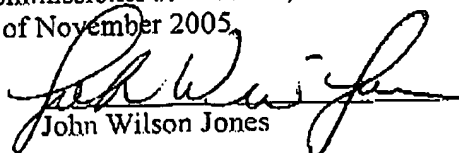
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CERTIFICATE OF TRANSMISSION, 37 C.F.R. § 1.6(d)

I hereby certify that this correspondence is being transmitted by facsimile, 571 273-8300, to Examiner Zakiya Nicole Walker c/o Commissioner for Patents, P. O. Box 1450, Alexandria, Virginia 22313-1450 on this the 10th day of November 2005.


John Wilson Jones